



US00D965243S

(12) **United States Design Patent**
Wang

(10) **Patent No.:** **US D965,243 S**

(45) **Date of Patent:** **** Sep. 27, 2022**

(54) **HAT RACK**

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(**) Term: **15 Years**

(21) Appl. No.: **29/813,333**

(22) Filed: **Oct. 28, 2021**

(51) **LOC (13) Cl.** **07-05**

(52) **U.S. Cl.**
USPC **D32/59**

(58) **Field of Classification Search**
USPC D32/59; D6/411, 315; D2/892, 181.4,
D2/891; 2/181, 171.3, 175.1, 209.12,
2/195.5; 34/87, 213, 201
See application file for complete search history.

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Primary Examiner — Austin Murphy

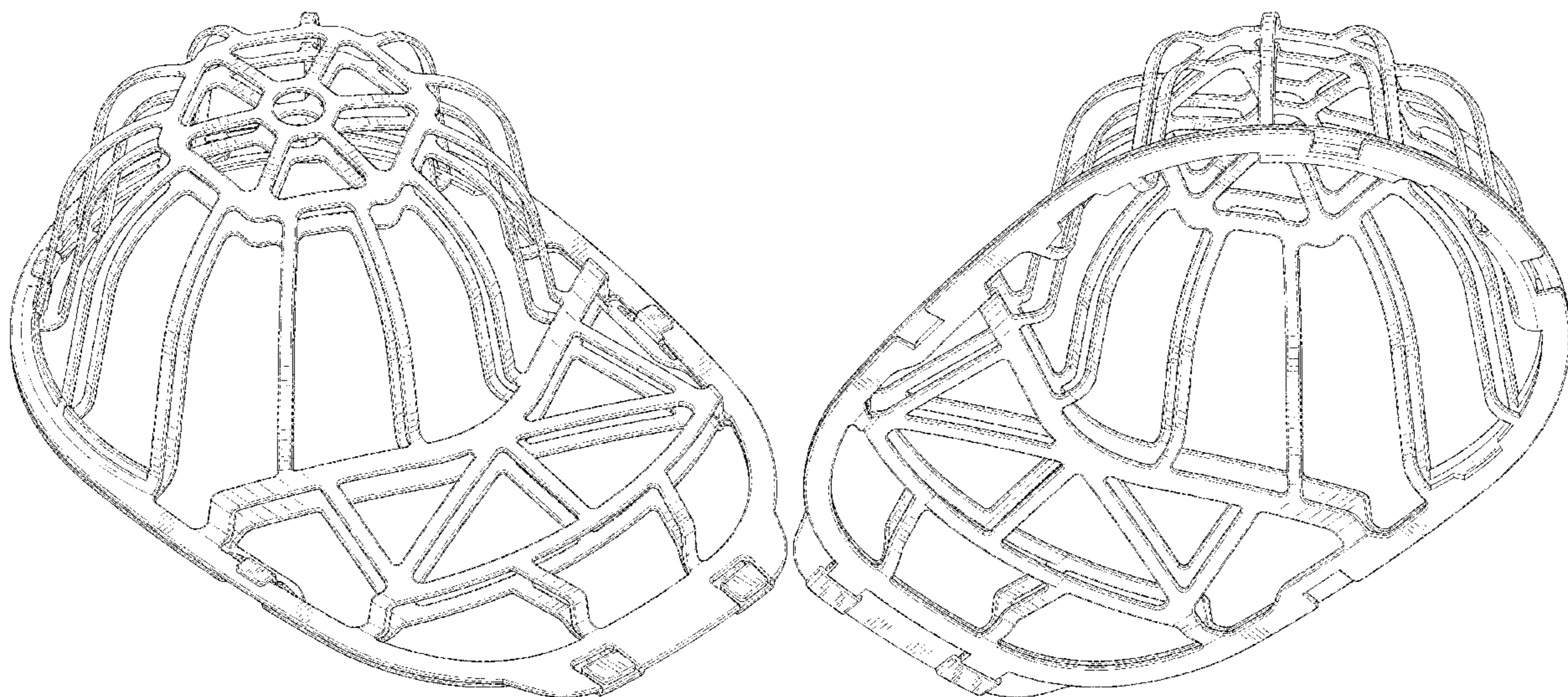
(57) **CLAIM**

The ornamental design for a hat rack, as shown and described.

DESCRIPTION

FIG. 1 is a perspective view of a hat rack showing my new design;
FIG. 2 is another perspective view thereof;
FIG. 3 is a front elevational view thereof;
FIG. 4 is a rear elevational view thereof;
FIG. 5 is a left side elevational view thereof;
FIG. 6 is a right side elevational view thereof;
FIG. 7 is a top plan view thereof;
FIG. 8 is a bottom plan view thereof; and,
FIG. 9 is an exploded perspective view of the hat rack.

1 Claim, 9 Drawing Sheets



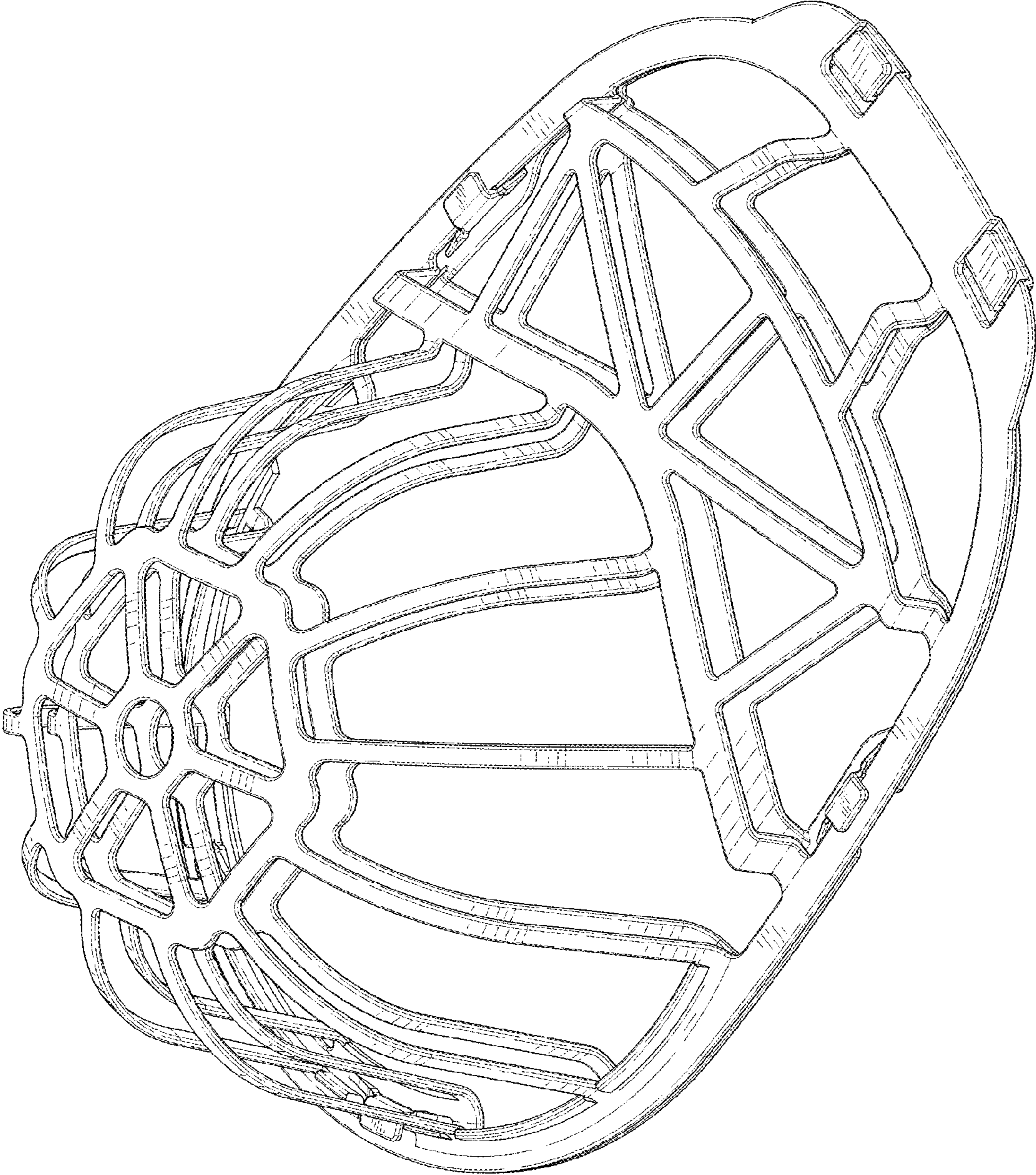


FIG. 1

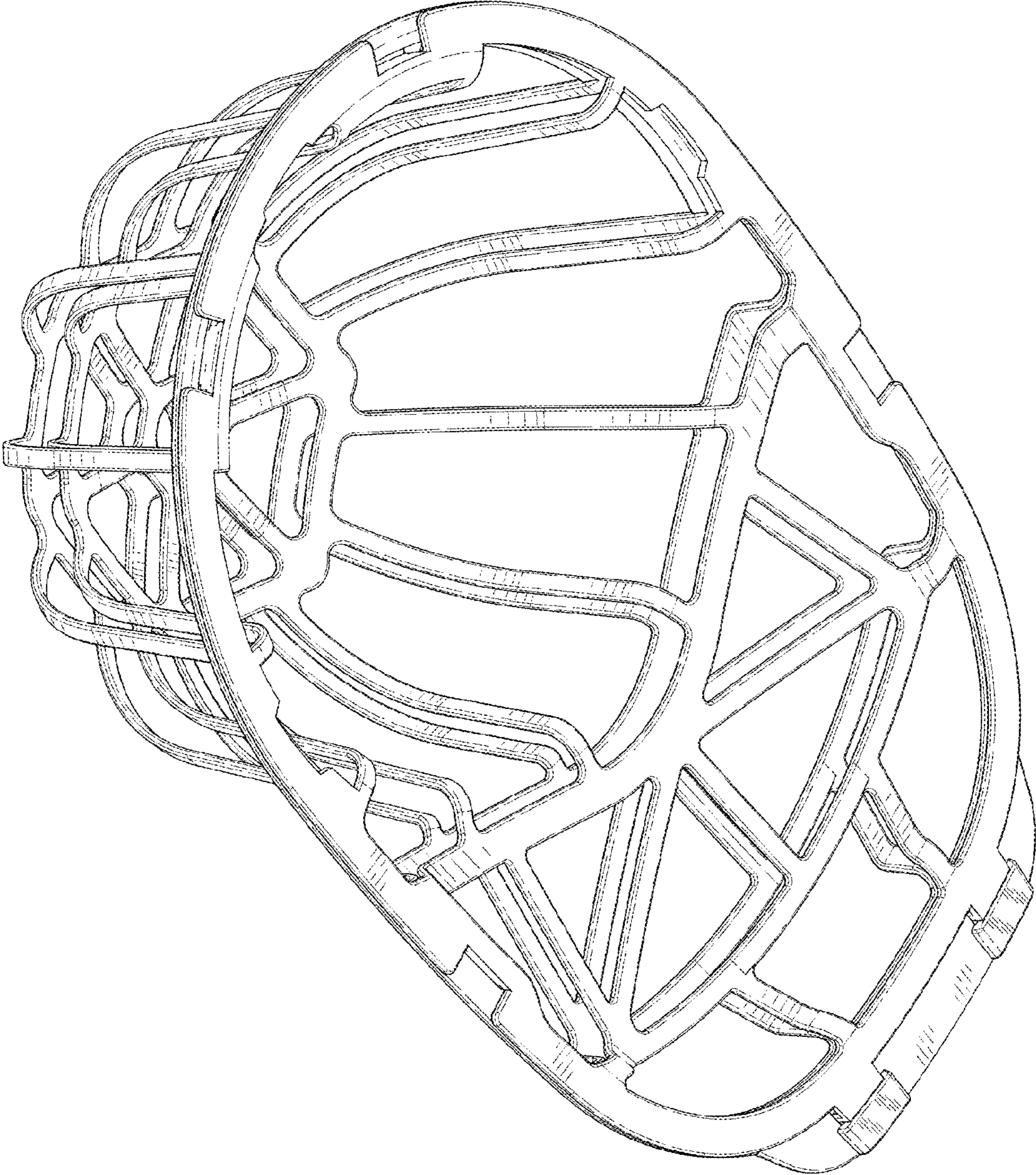


FIG. 2

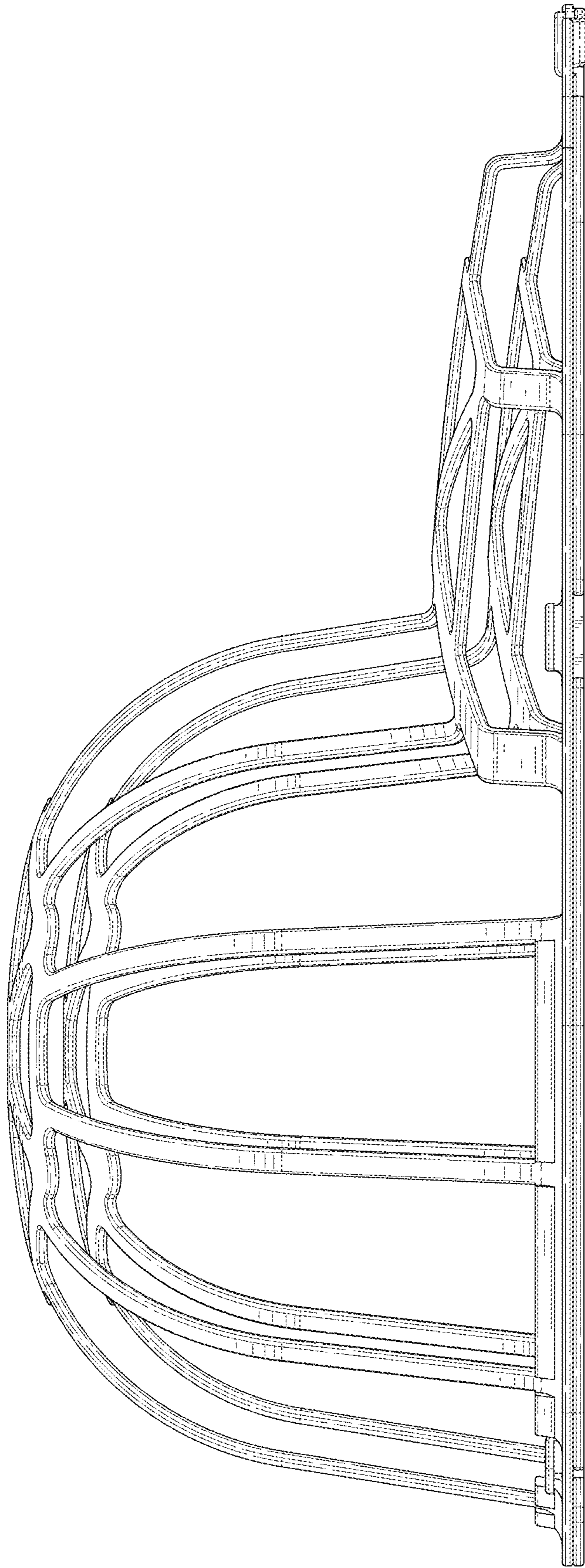


FIG. 3

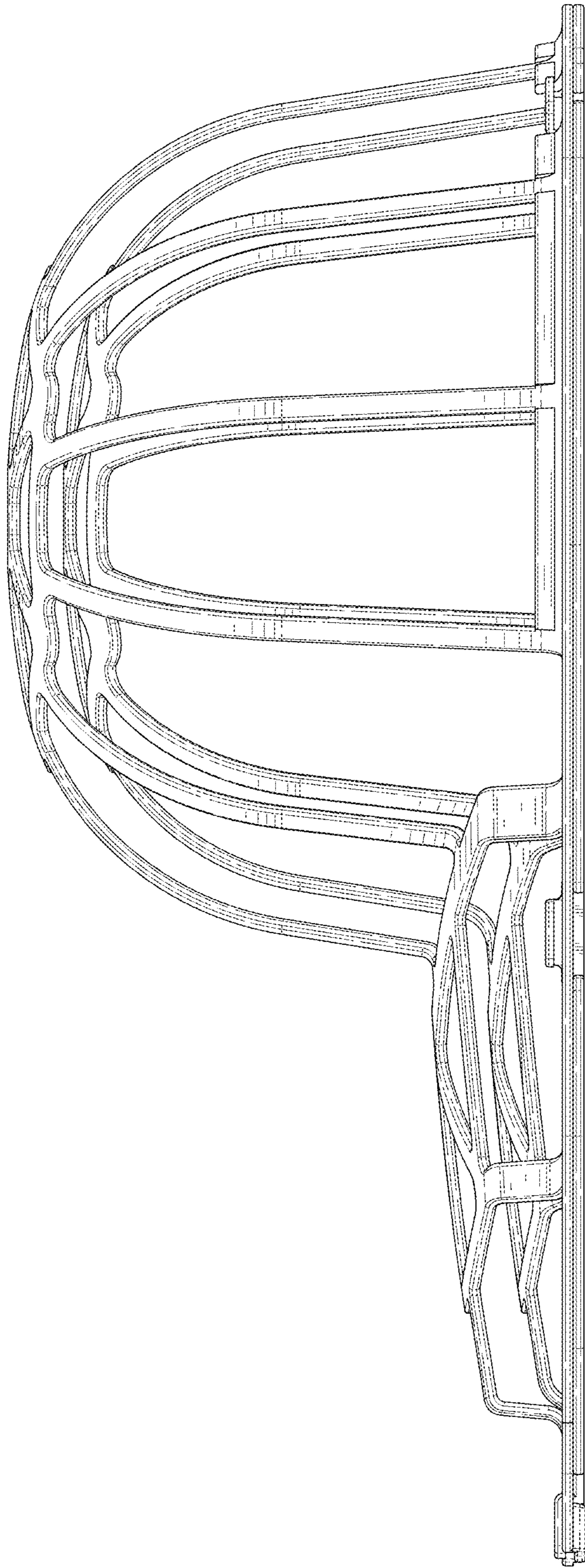


FIG. 4

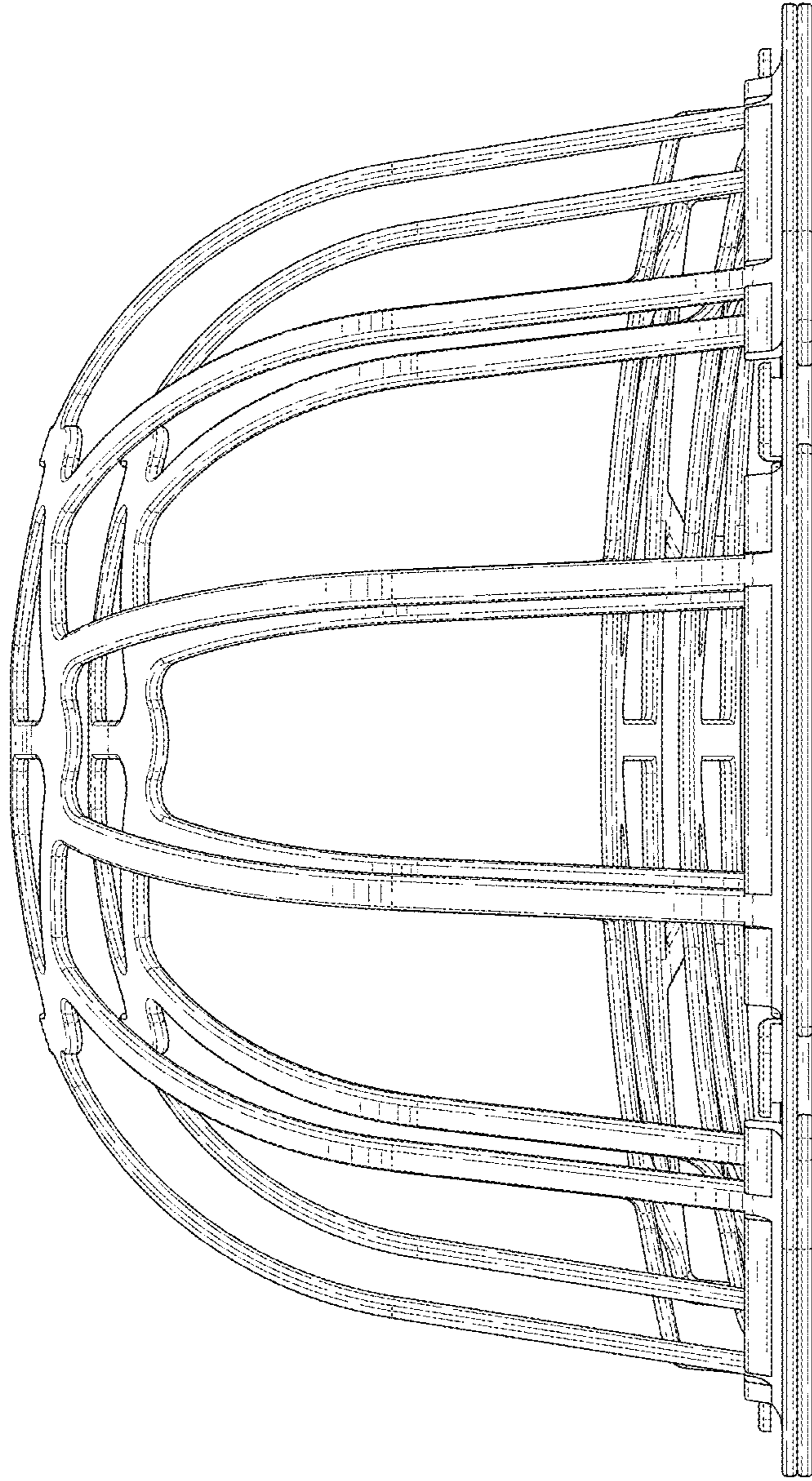


FIG. 5

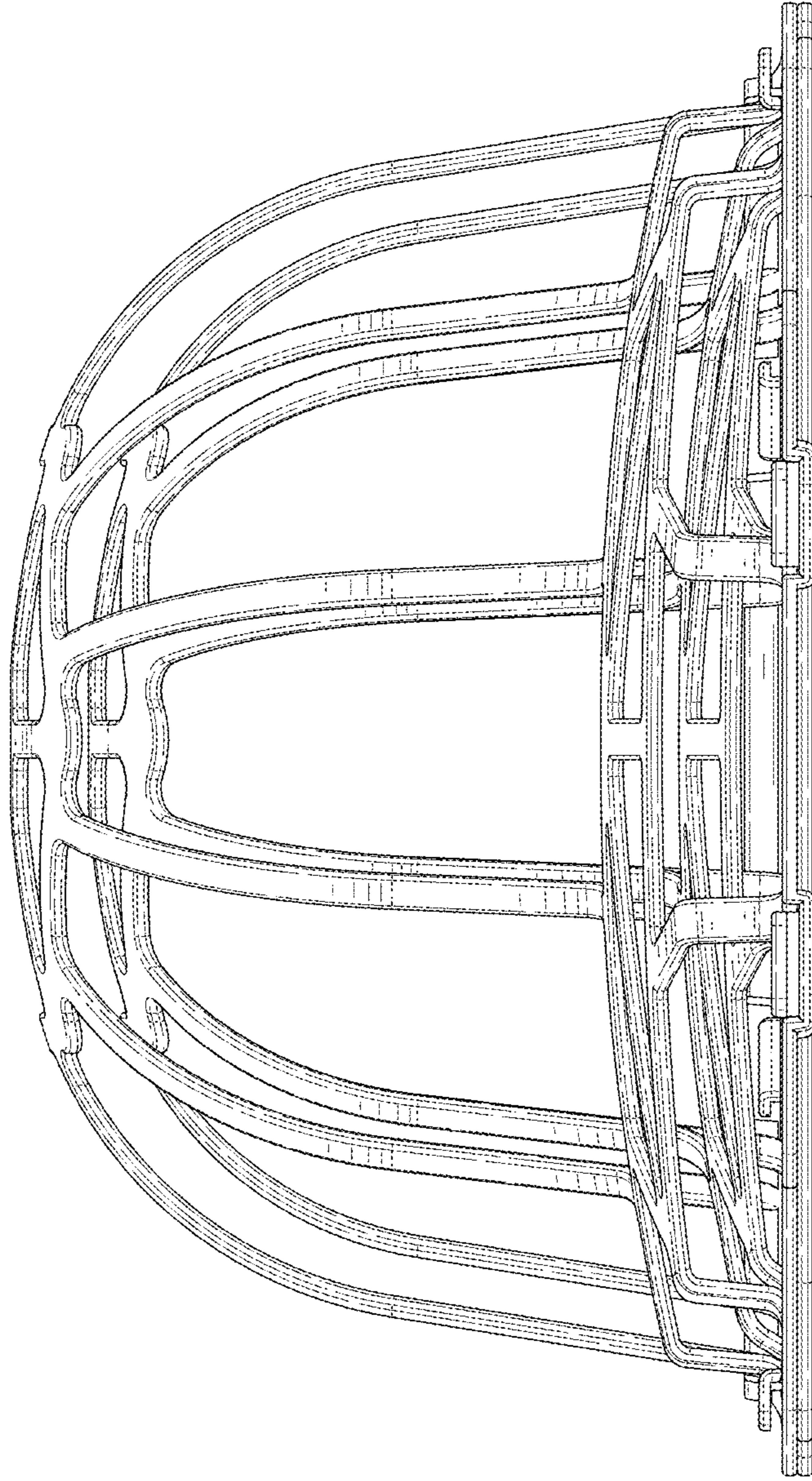


FIG. 6

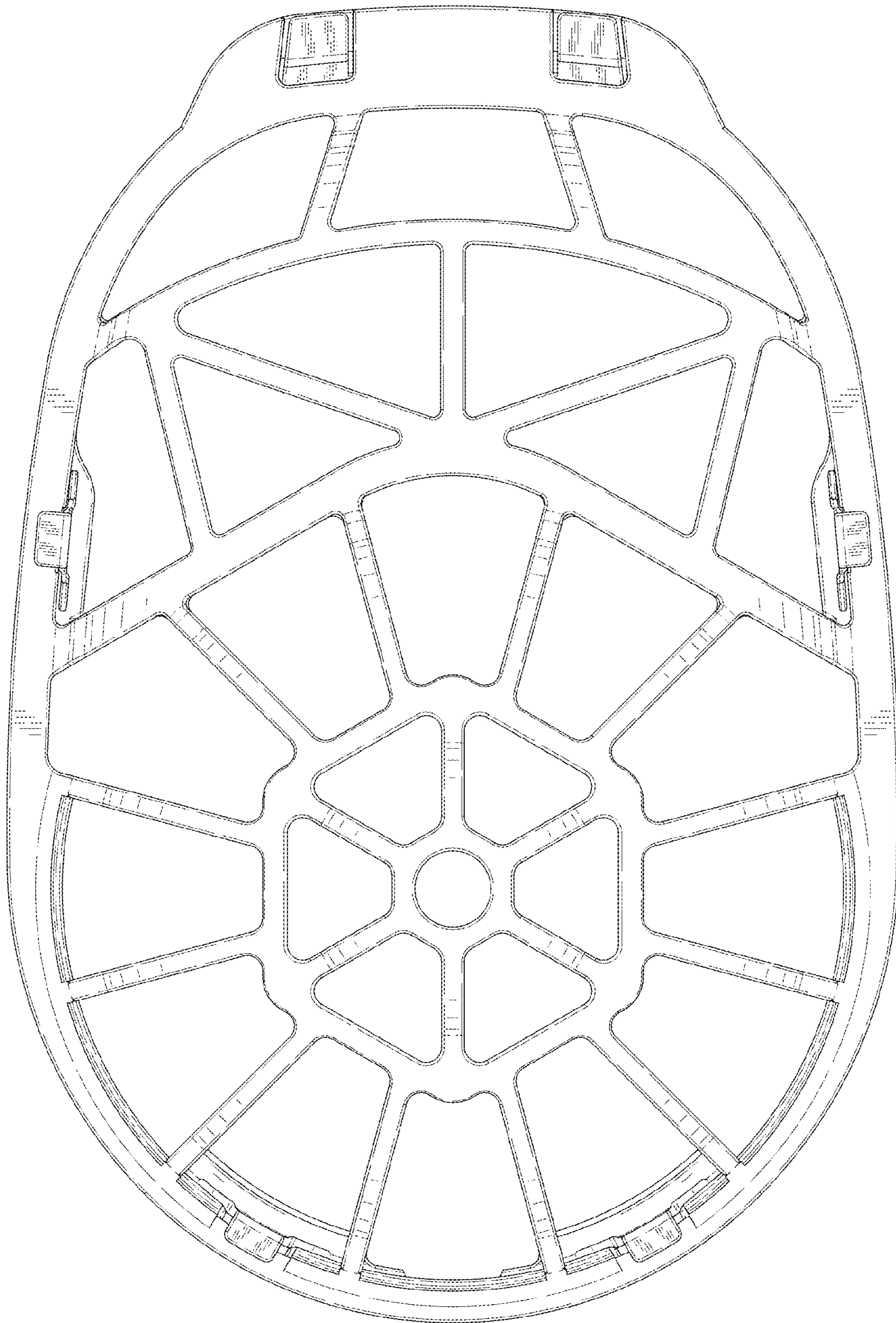


FIG. 7

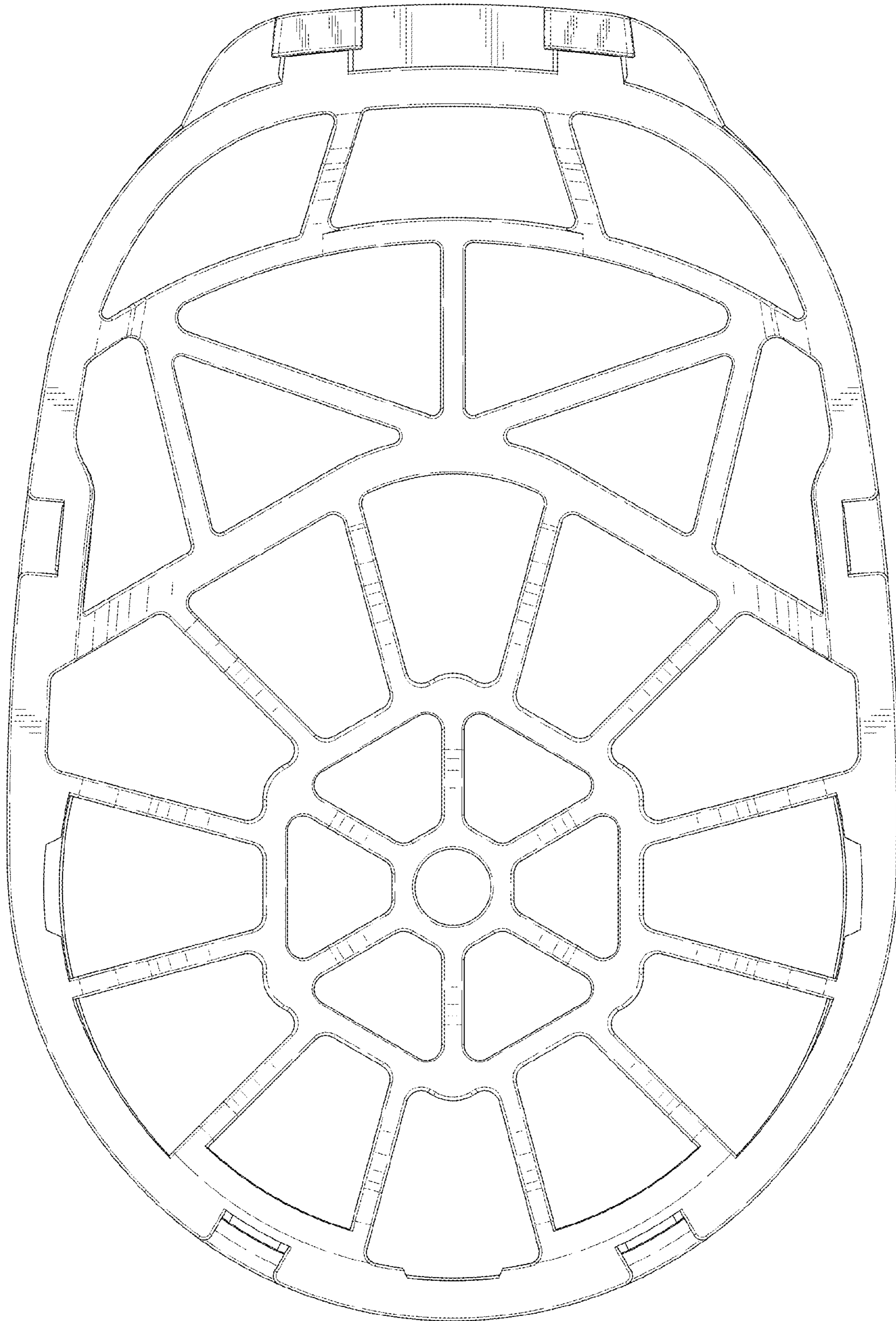


FIG. 8

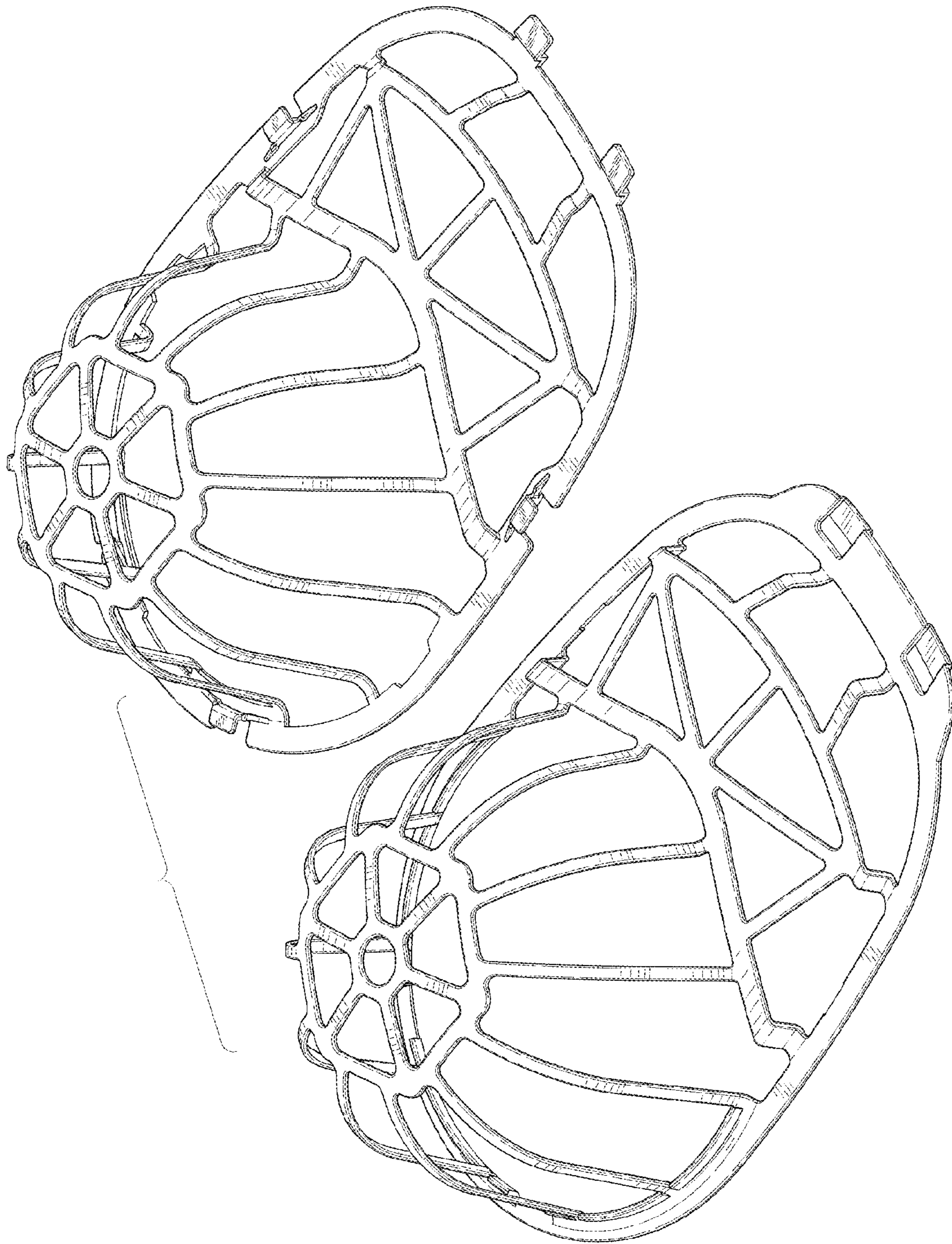


FIG. 9